

# A Non-Contact Interconnect Technology for Reducing Semiconductor Chip Cost

2006

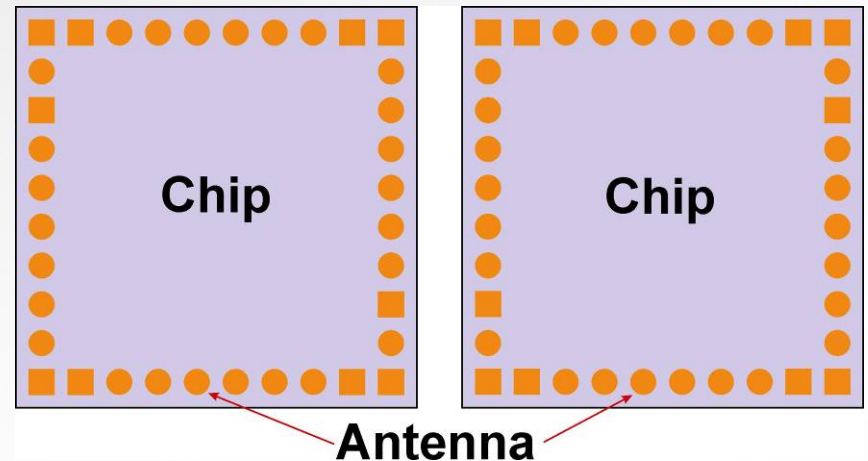
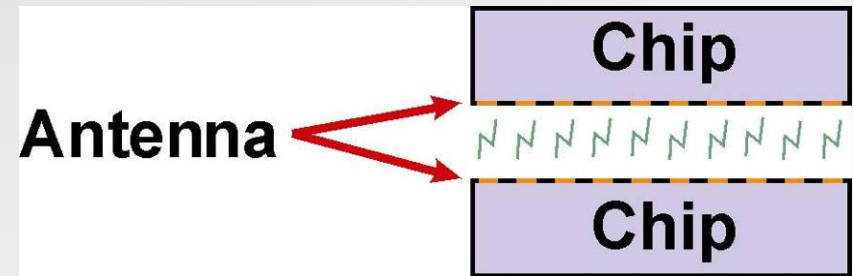
CMOS Emerging Technologies Workshop  
Banff, AB



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Jeff Hintzke, Brian Moore

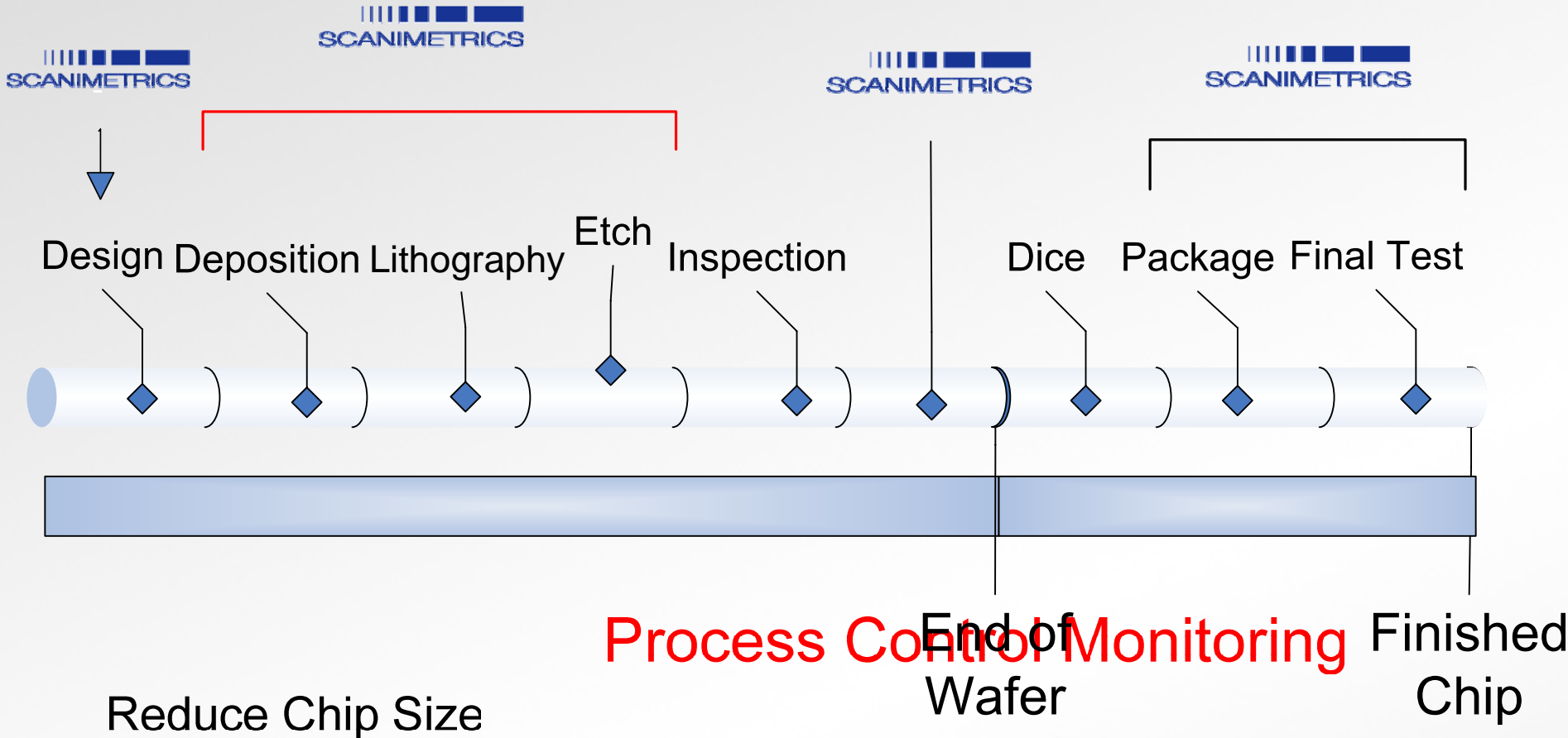
1. Technology overview
2. Application summary
3. Results of development
4. Conclusion

- Disruptive technology which enables new testing techniques and capabilities
- Wireless chip-scale communications
- Distances  $<100 \mu\text{m}$



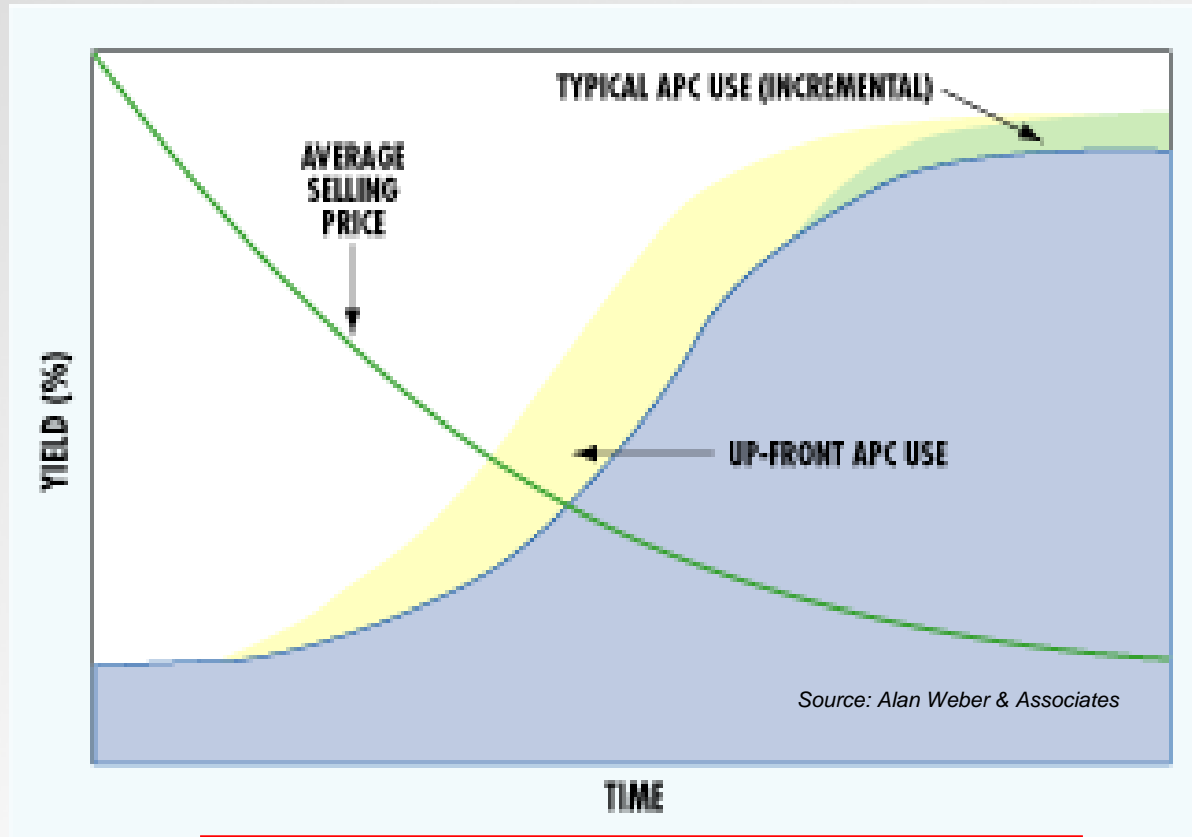
- Technology is “non-contact”
  - Chips can be smaller
  - Manufacturing process can be monitored
  - More chips can be tested at once
  - No damage during testing
- Chips are less expensive and production is more efficient

Technology adds value at several points in the value chain.



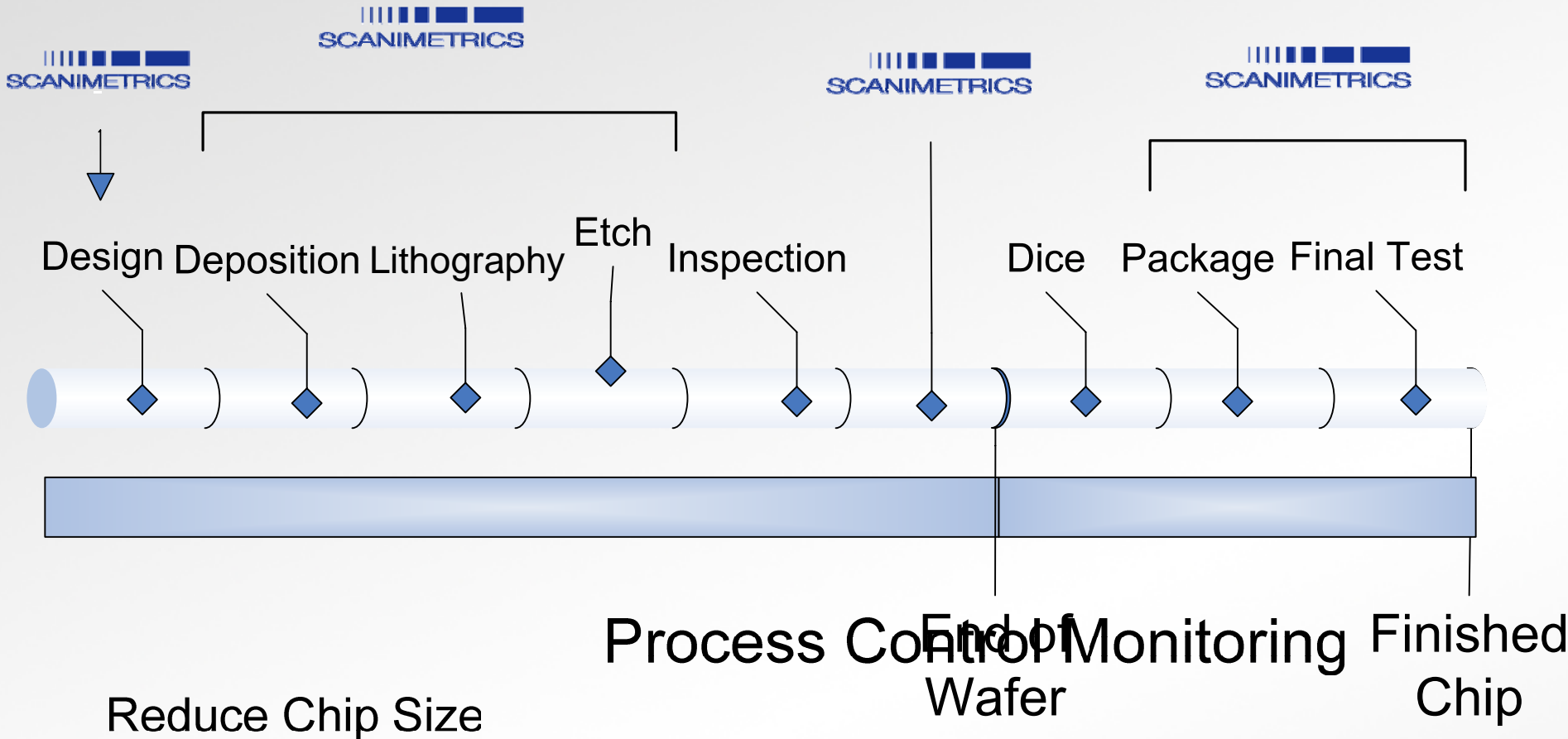
- Circuits can be tested after 1<sup>st</sup> metal layer
- Full wafer, multi-site testing capability
- Most PCM tests can be duplicated wirelessly
- Certain wireless tests may be done earlier or later in the process
- DC parametric tests
- AC parametric tests

**Applying Automatic Process Control early in a fab's life cycle can yield significant returns**

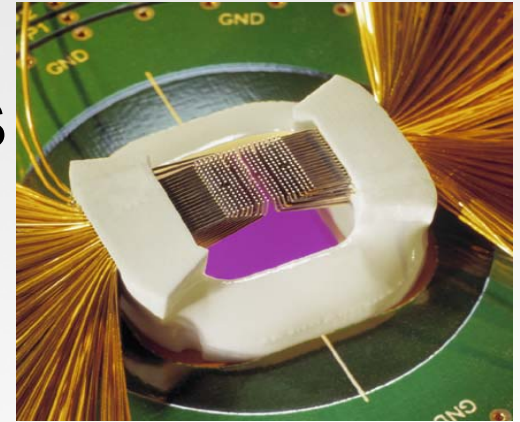


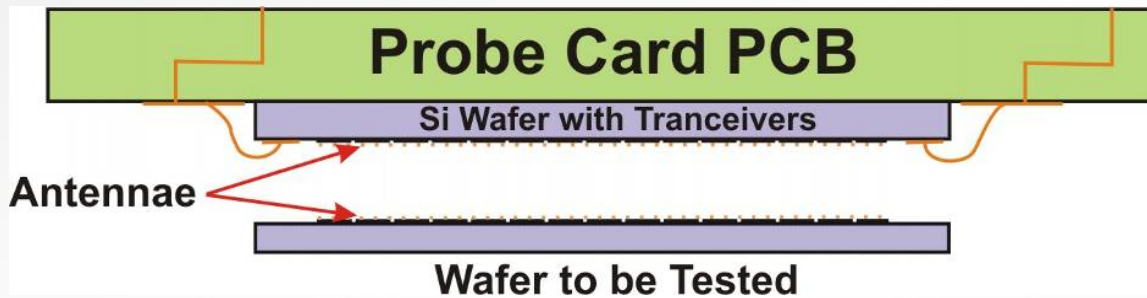
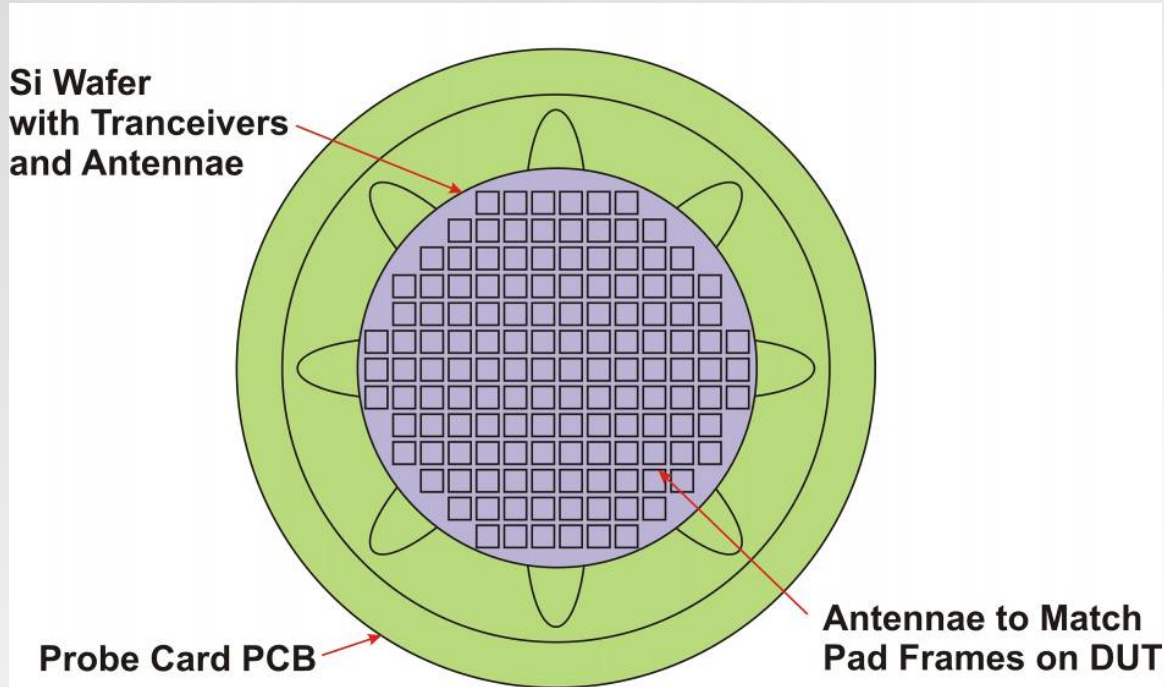
**Enables the earliest possible in-situ process monitoring, shortening a fab's "time to money".**

Scanmetrics adds value at several points in the value chain.



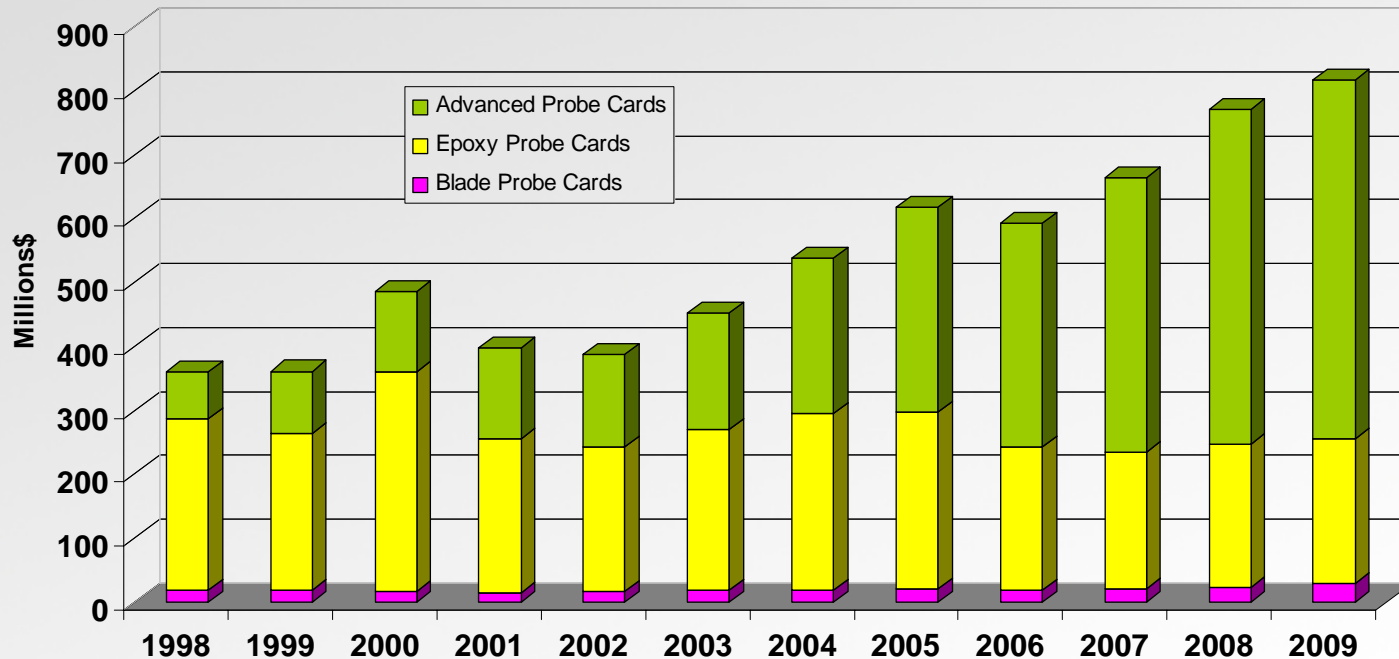
- Increases chip costs
- Limits technological advances
- Limits throughput
- Damages chips
- Current industry participants:





- Probe separation proportional to pitch
- Wireless power transfer  $>100\text{mW}$
- Separate antennae/probes for power transfer
- Hi-rel signal i/o, eliminates contact force and scrubbing issues
- Lower alignment accuracy requirements than mechanical probes
- Scaling
  - Gbps test speeds
  - Highly parallel testing
  - Probe pitch
- Processes
  - Compatible with existing equipment and processes
  - Capability to work with new materials (low-k dielectrics)

**The Probe Card Market 1998-2009**  
(\$M Revenue, by type)

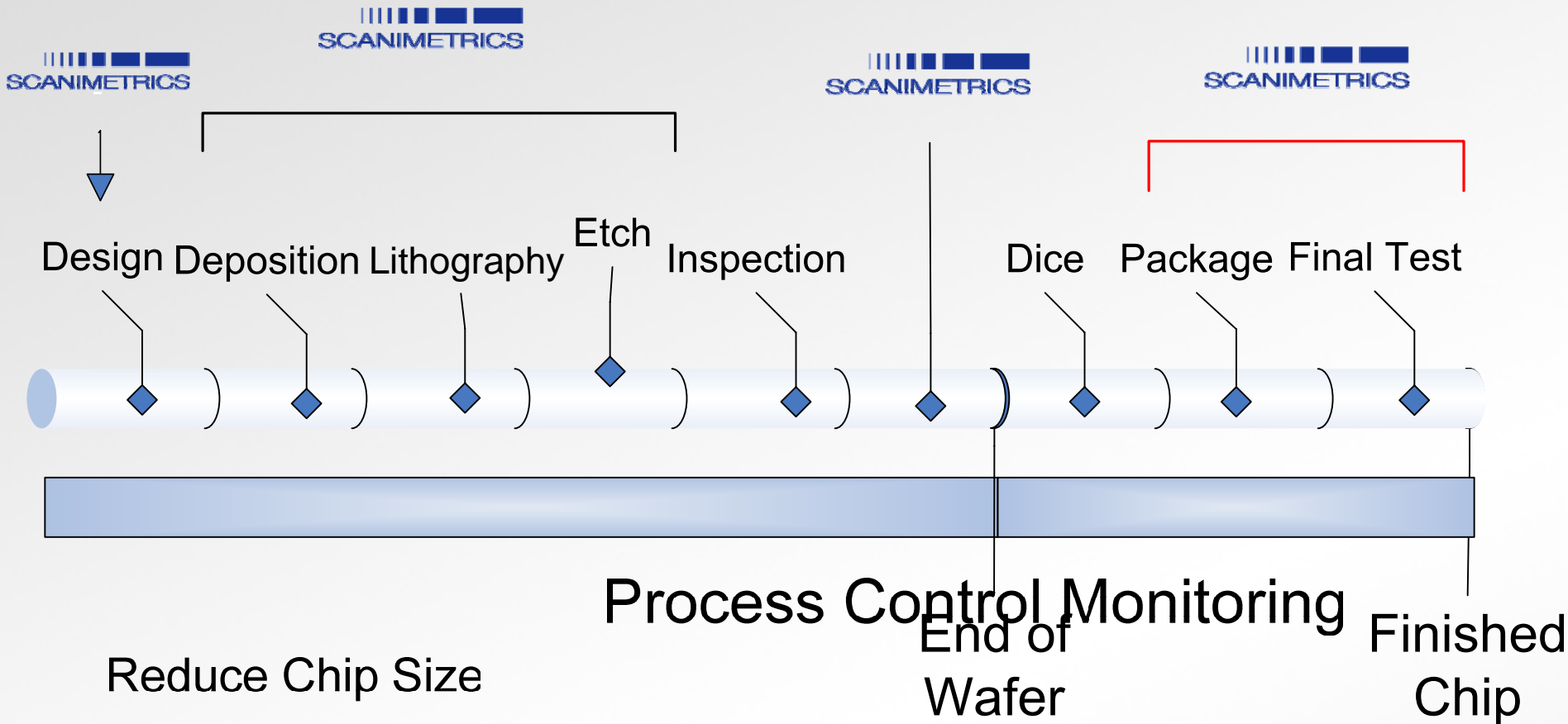


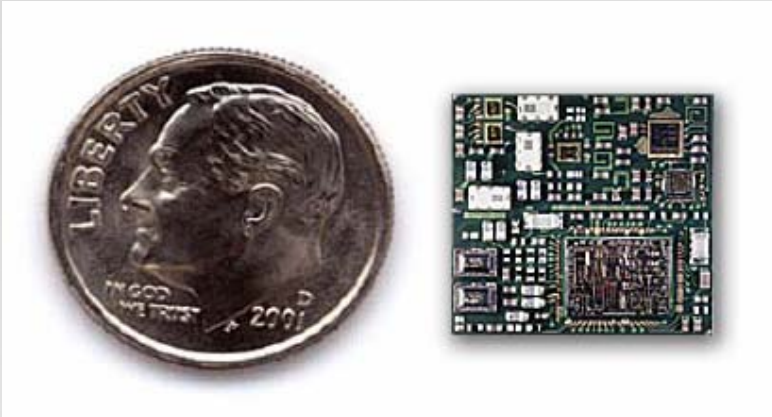
Source: VLSI Research 05/04

- The real 2006 figures are already exceeding the 2008 predictions
  - It is expected to grow 19.1%, following 19.5% growth to \$838 million in 2005

- VLSI Research Inc (06/06)

Scanmetrics adds value at several points in the value chain.

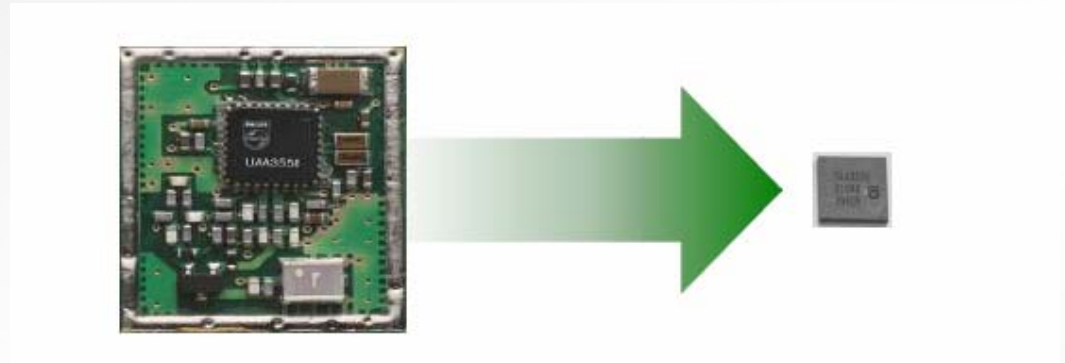




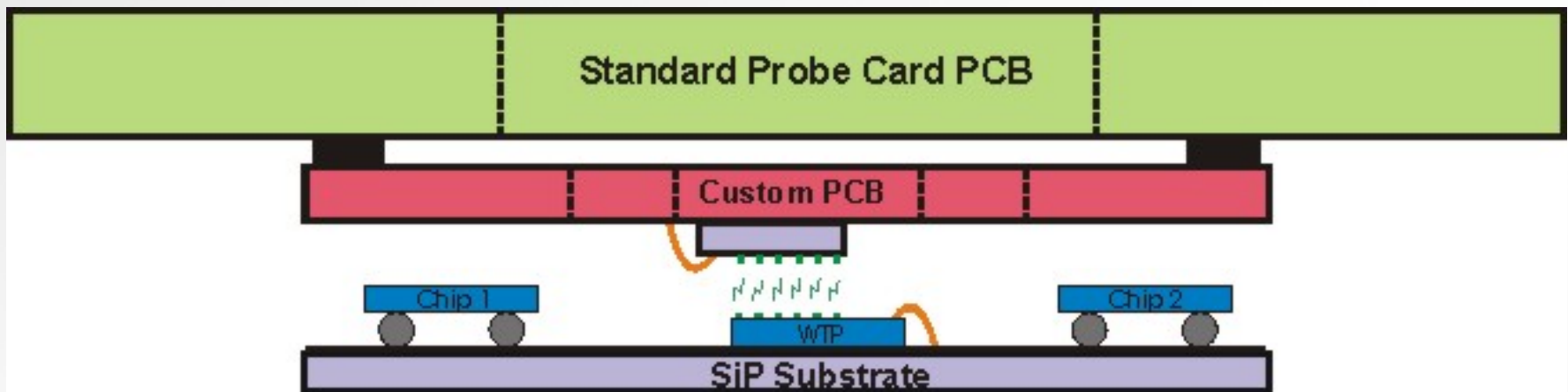
## SiP "System in Package"

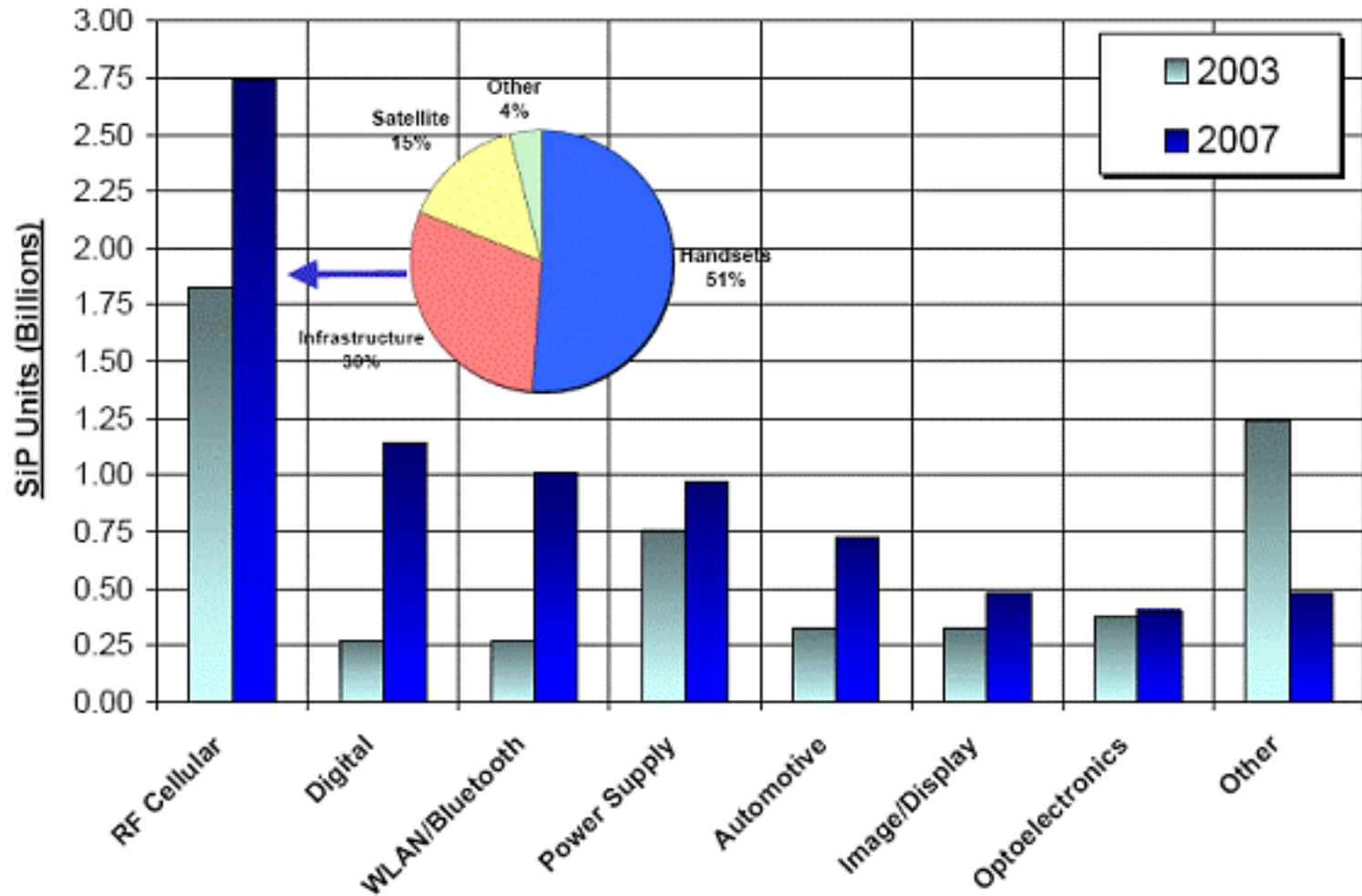
SiP is an rapidly advancing technology for dramatically reducing chip size by combining smaller chips on a host chip thereby eliminating much of the packaging

Scanimetrics is an enabling technology for SiP by allowing testing of each chip component as they populate the host chip



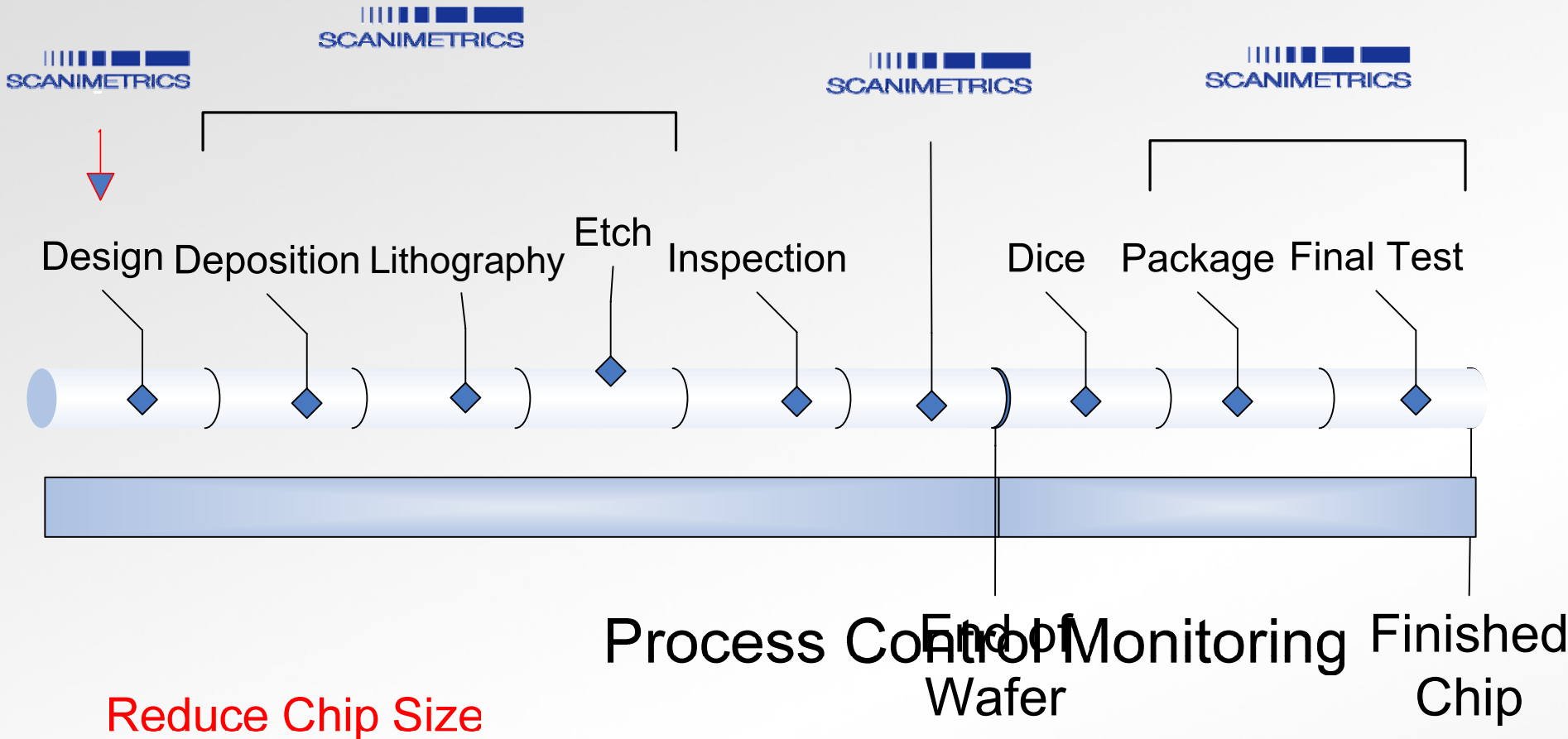
- Wireless Test Port (WTP)
  - Allows testing during the assembly process so bad “KGD” and assembly errors are detected early
- Increases yield of SiP device
- Reduce discard of good die





Sources: Prismark .

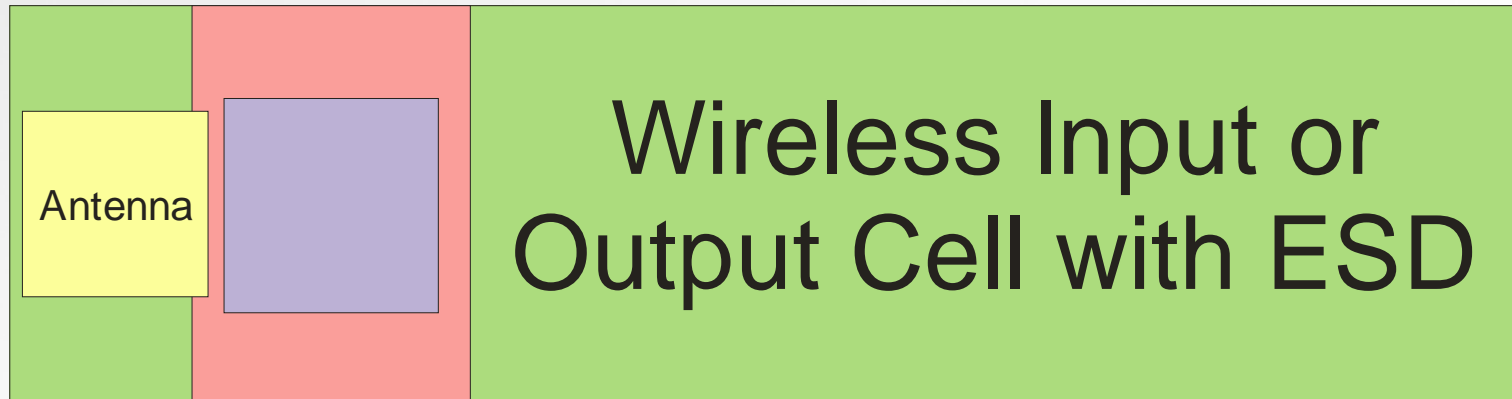
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 Active Circuitry

 Transceiver Circuitry

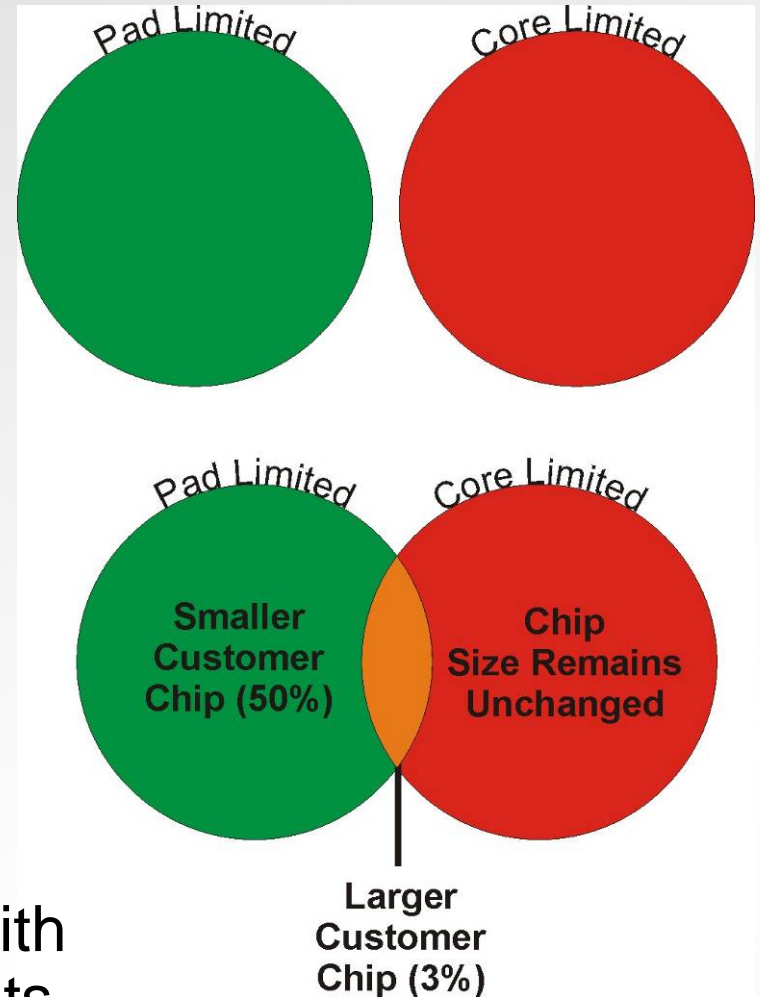


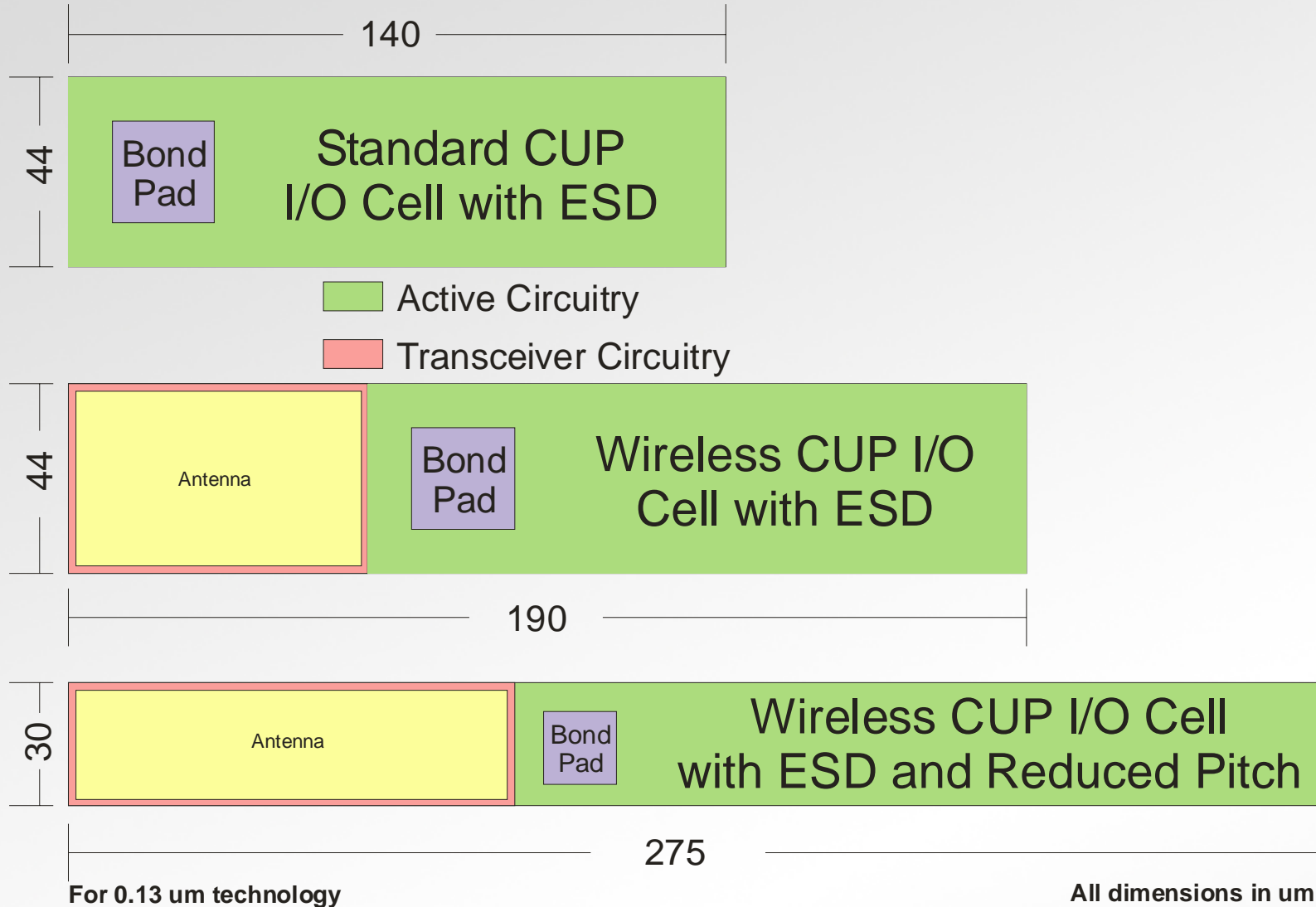
Chip size w/o Scanimetrics

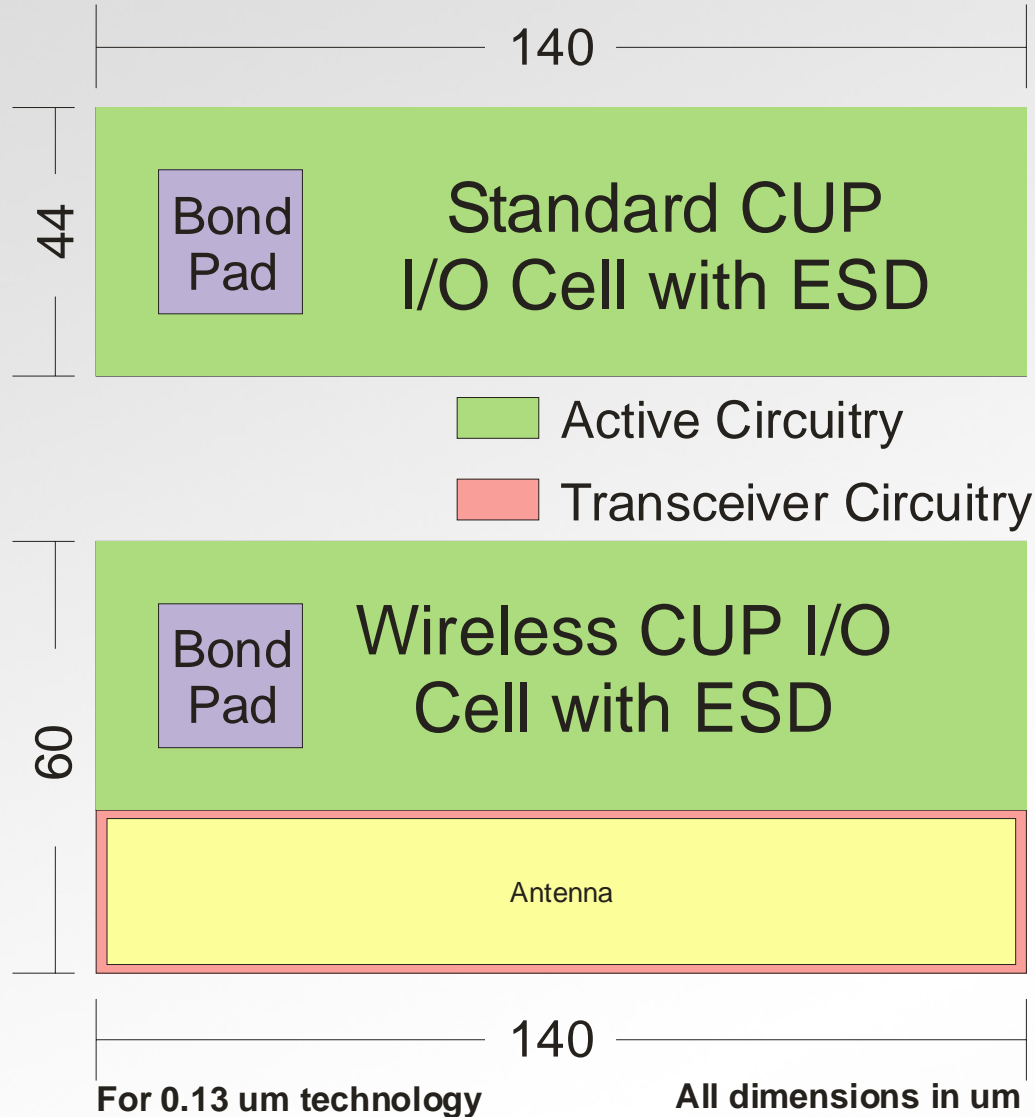


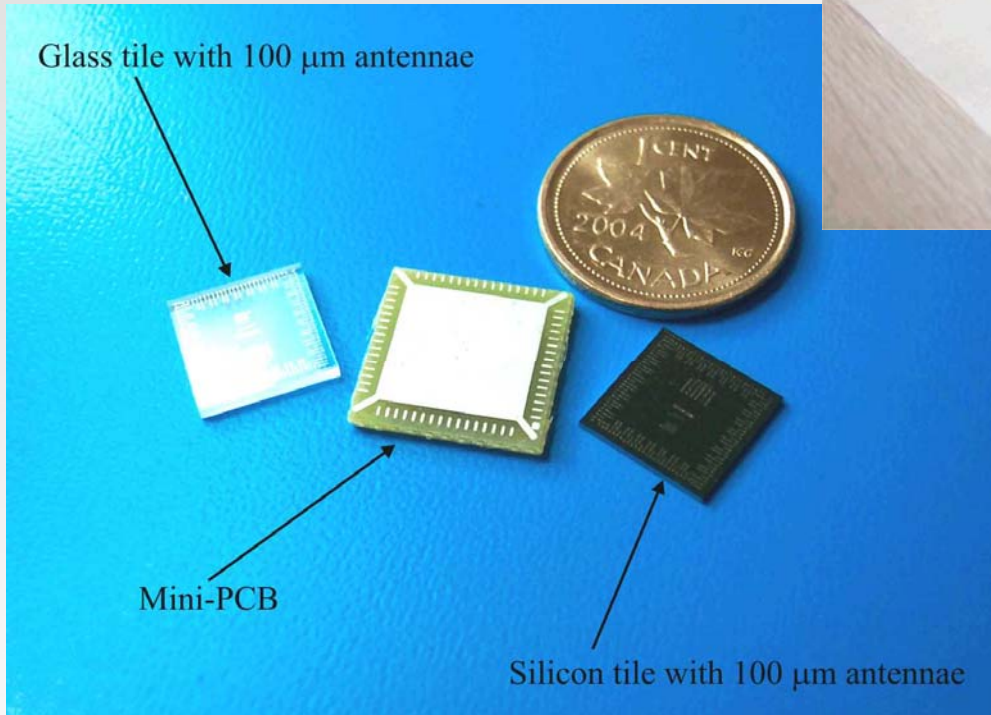
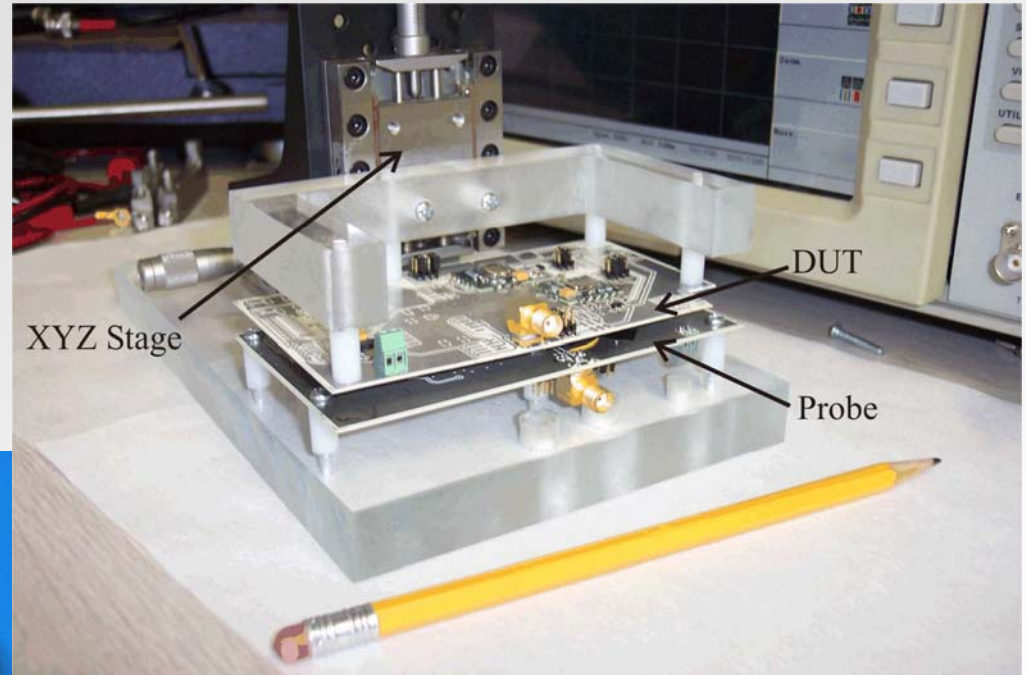
Chip size with Scanimetrics

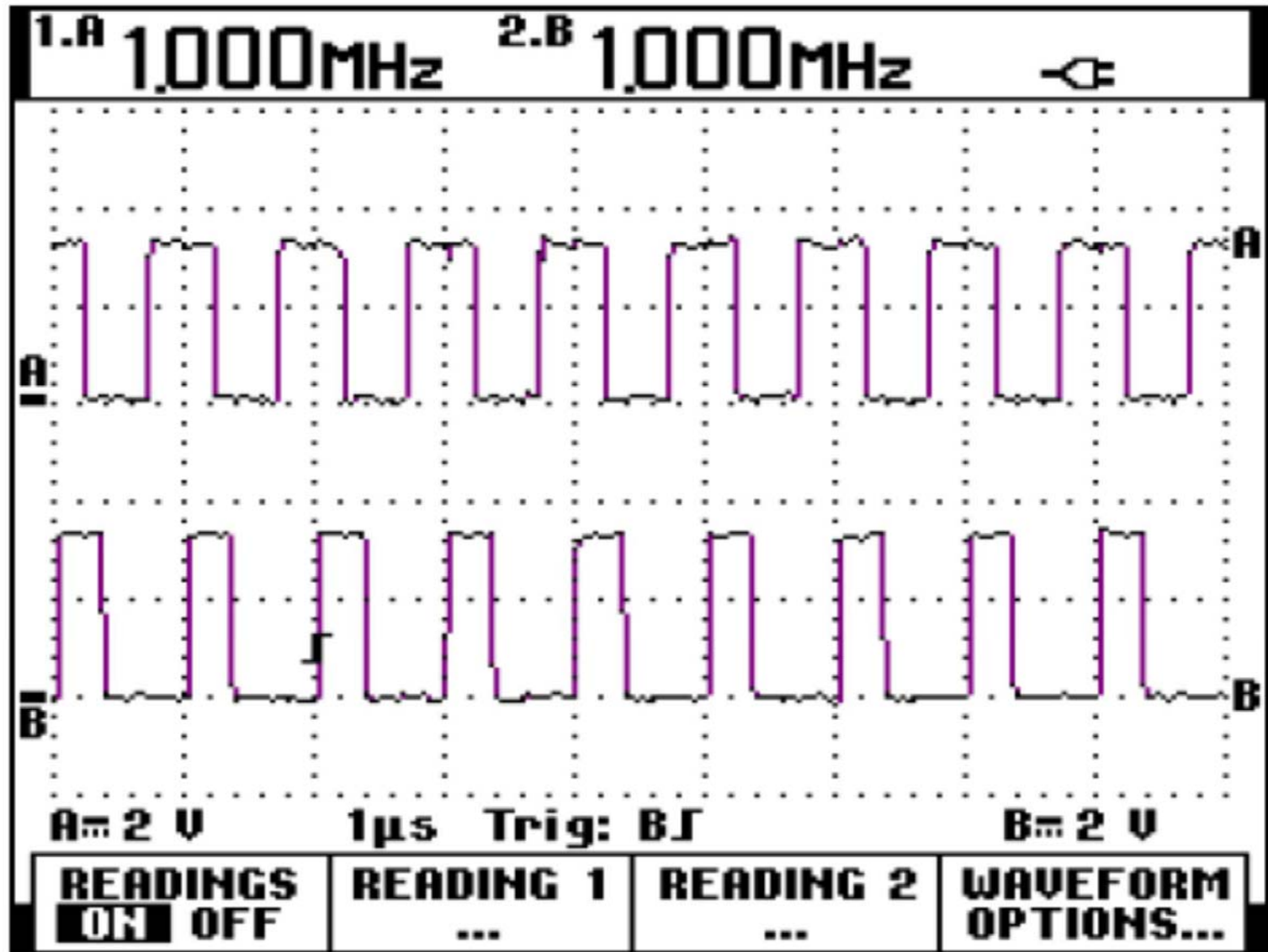
Supports internal test points with no ESD protection requirements

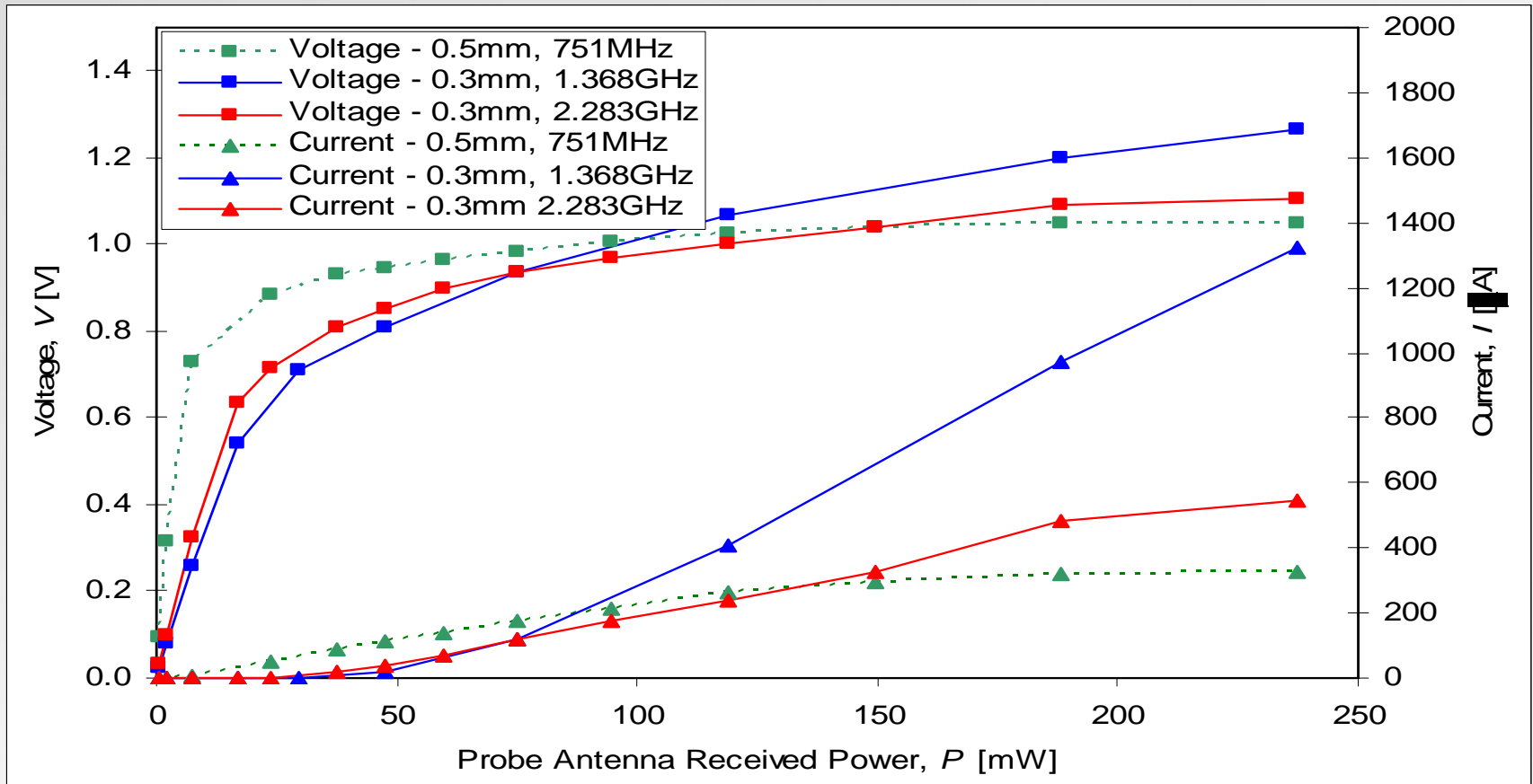


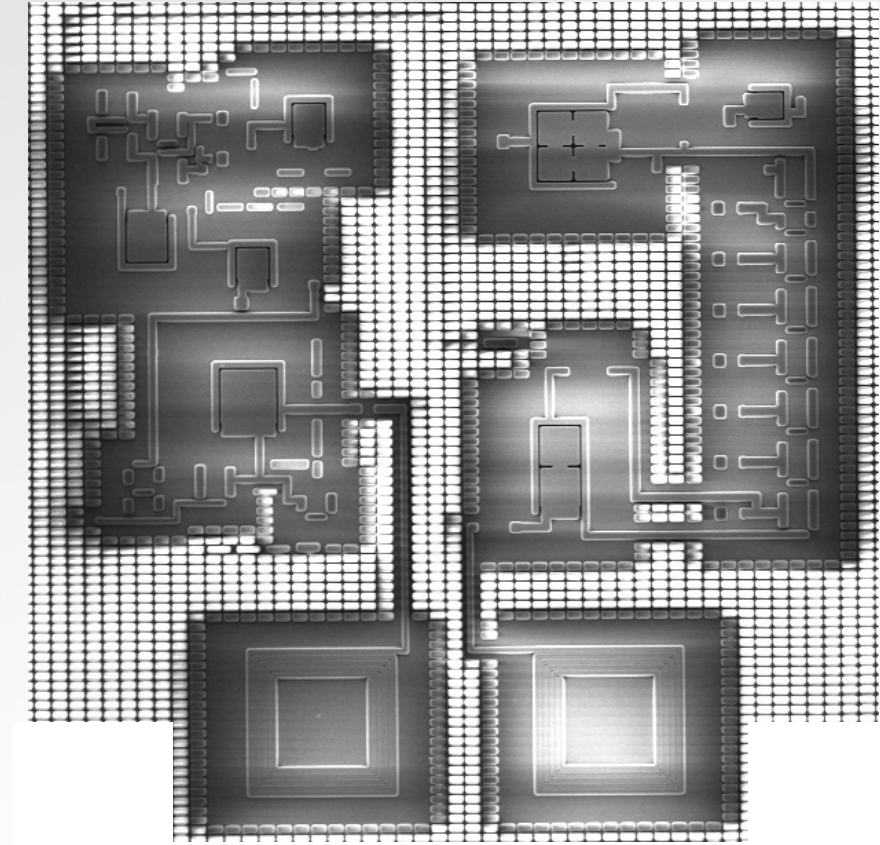
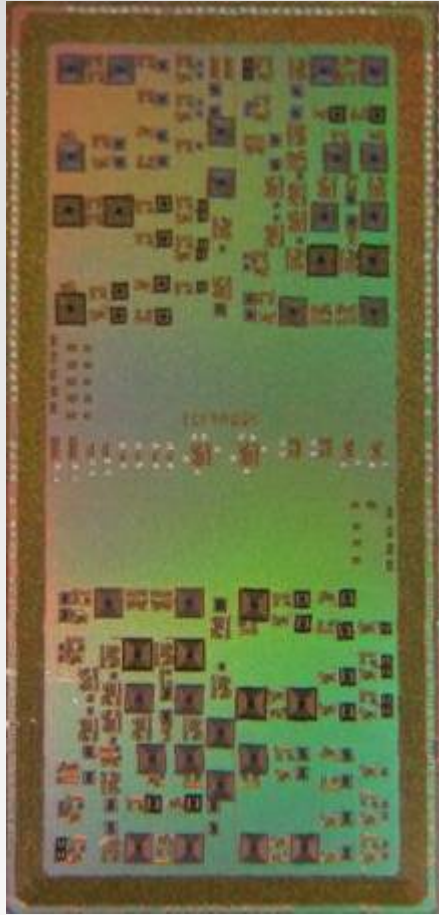


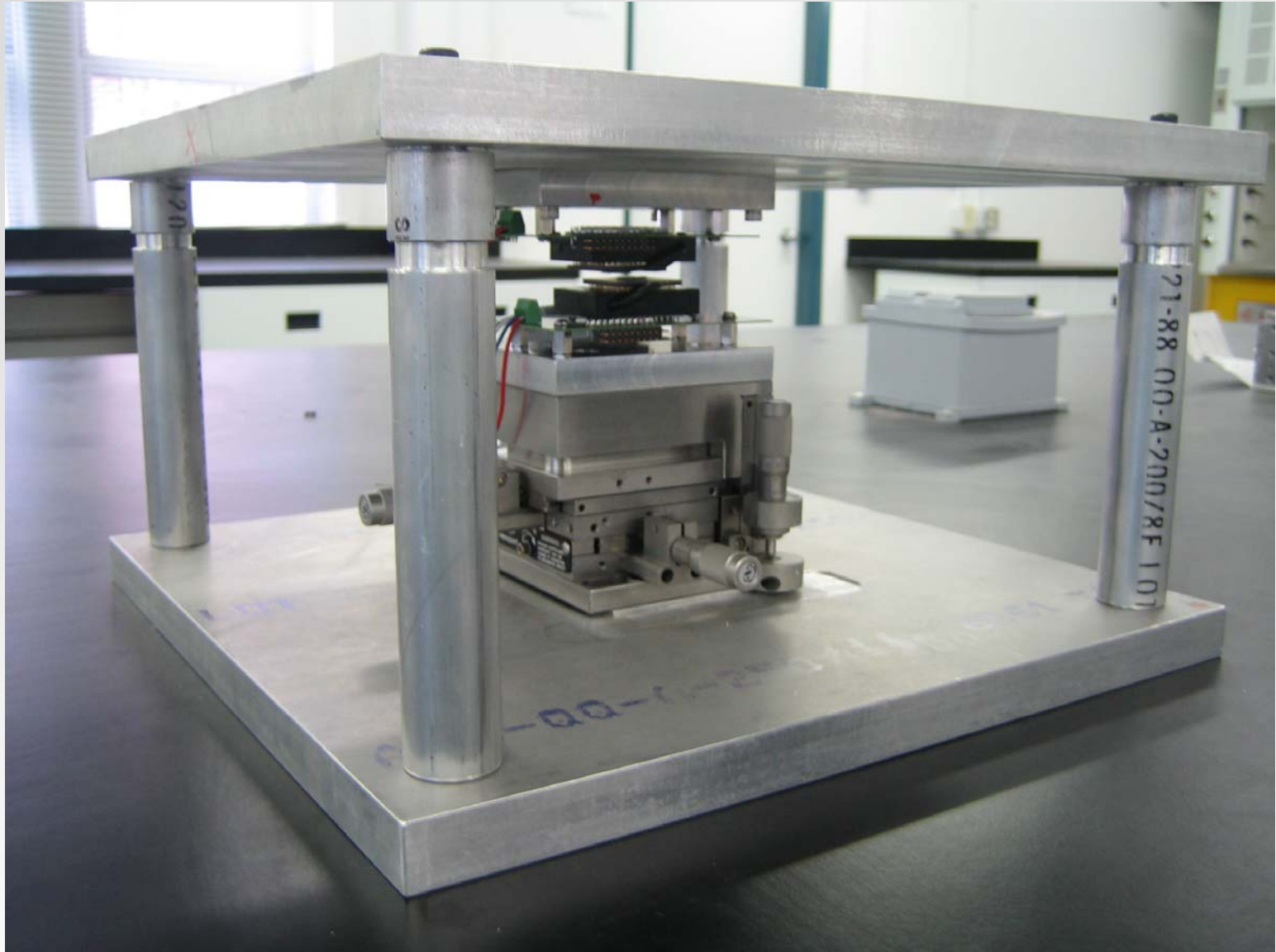


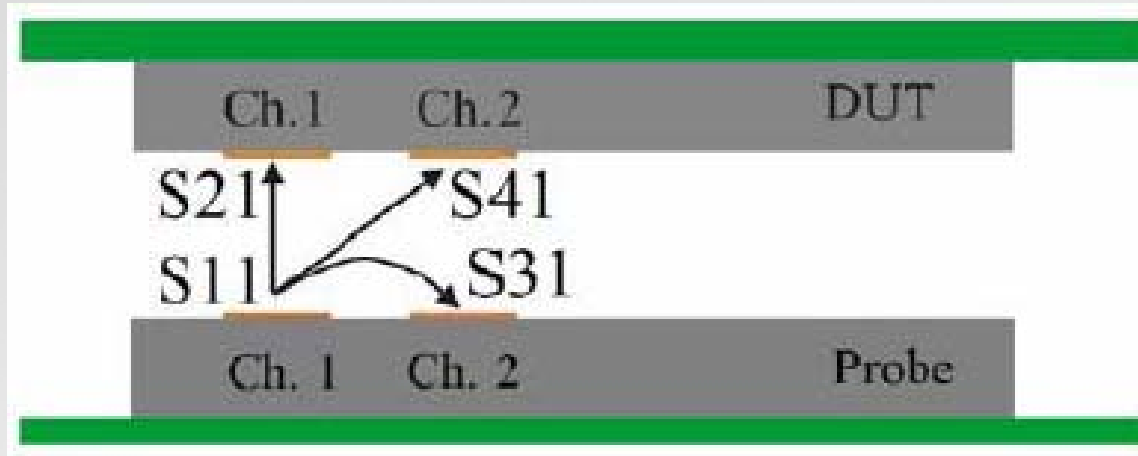




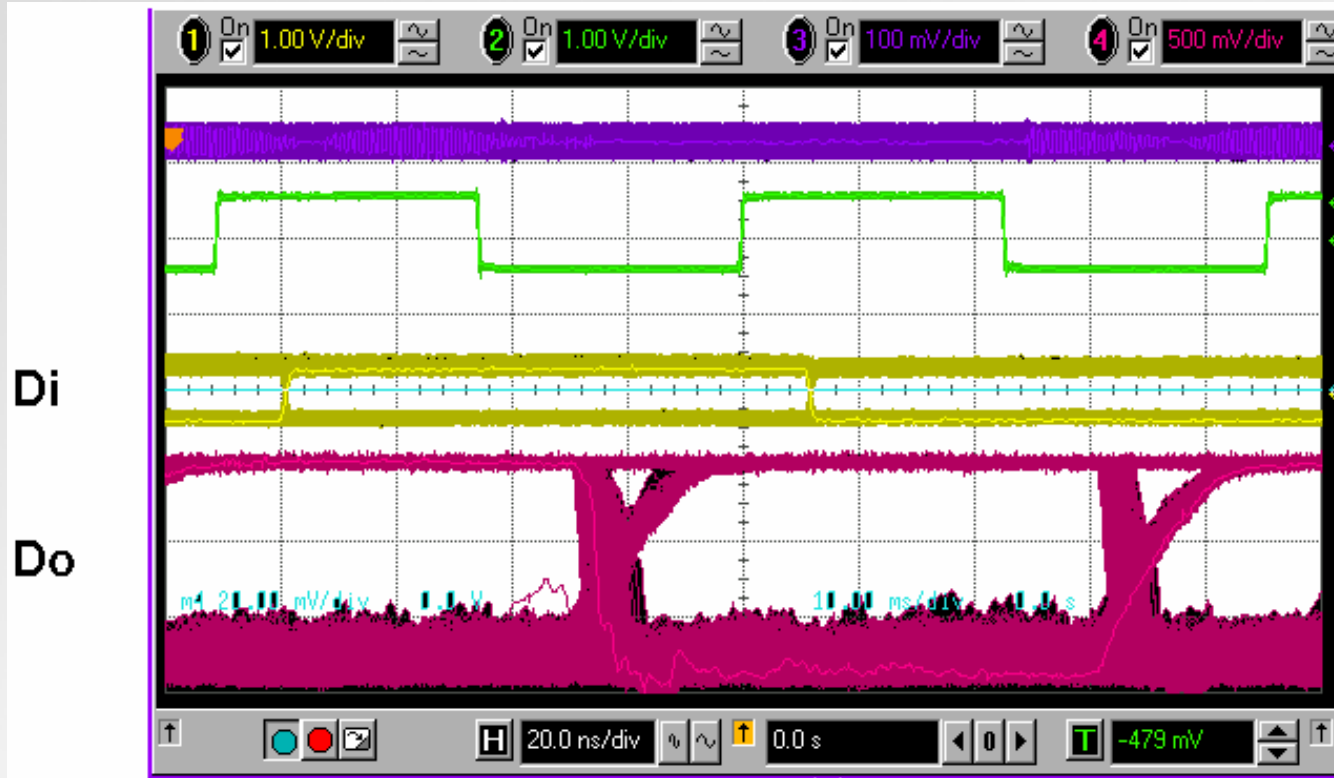




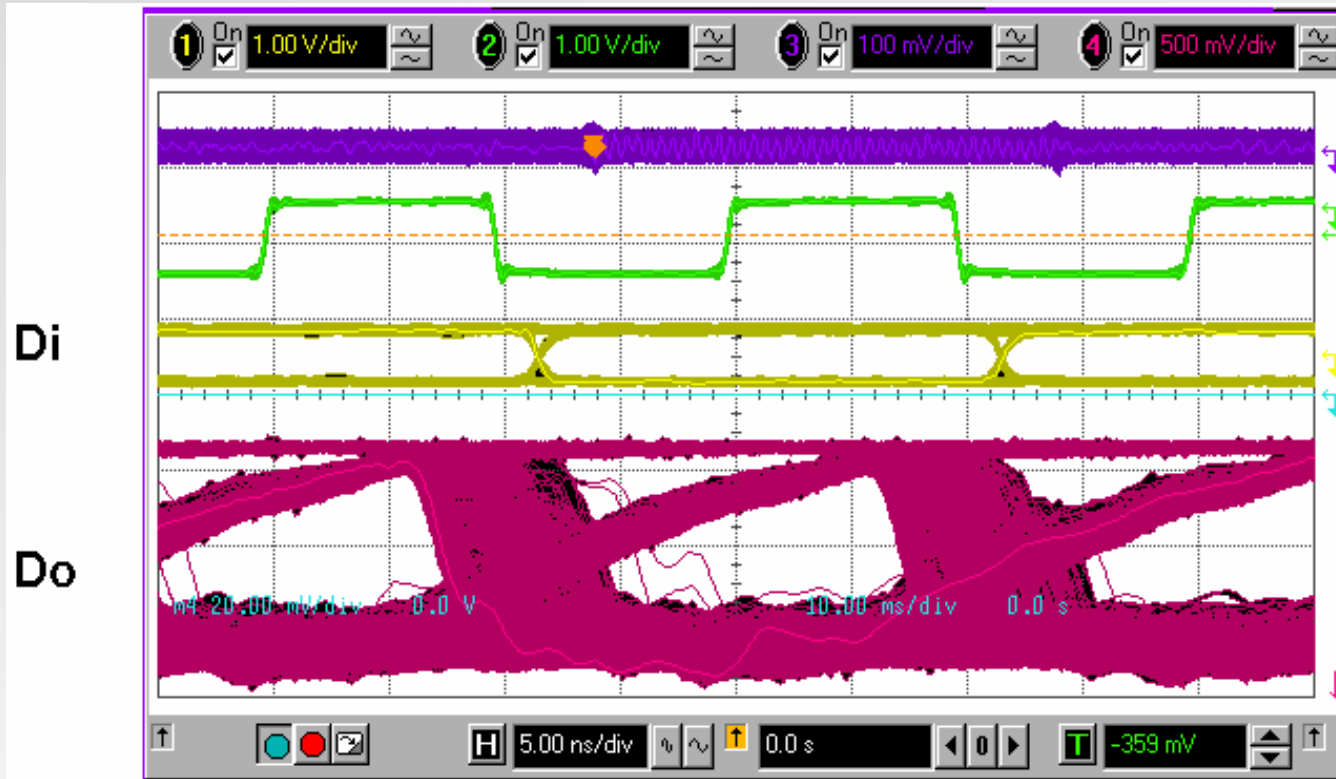




Parameter	Size=60 $\mu$ m, $f = 5$ GHz, $z = 60\mu$ m	
	$x = 30\mu$ m	$x = 60\mu$ m
S21	-32dB	-32dB
S31	-44dB	-50dB
S41	-56dB	-55dB



Eye Diagram of 20 MBPS data signal



Eye Diagram of 100 MBPS data signal

- Bit error rate better than  $10^{-12}$
- 180nm process
  - Technology scales well
  - Two designs validated at two foundries
  - 130nm in fabrication
- Coupling devices 60um
  - Second generation 18um, 10x perf/size
  - Third generation, 10x perf/size

- Dramatically reduces chip manufacturing cost
- Enables new System in Package (SiP) technologies
- Vastly improves:
  - Chip size
  - Manufacturing control
  - Testing

“(Scanimetrics) technology is seminal in nature and the impact will be profound.”

(Denny Sabo, former CEO, Arithmos)



Thank you!